

INFORMATION DISCLOSURE STATEMENT 37 C.F.R. § 1.97(b)		ATTORNEY DOCKET NO. 70020.0067USWO	
		U.S. APPLICATION SERIAL NO. 10/541,032	CONFIRMATION NO. 4015
		FILING DATE June 28, 2005	
INVENTOR(S) Isao NISHIMURA et al.		EXAMINER Unassigned	
		GROUP ART UNIT N/A	
TITLE OF APPLICATION RADIATION-SENSITIVE RESIN COMPOSITION			

Mail Stop PCT
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

With regard to the above-identified application, the items of information listed on the enclosed Form 1449 are brought to the attention of the Examiner.

This statement should be considered because it is submitted before the mailing date of a first Office Action on-the-merits. Accordingly, no fee is due for consideration of the items listed on the enclosed Form 1449.

A copy of any foreign patent document or 'Other Document' listed on the Form 1449 is enclosed, in accordance with 37 C.F.R. §1.98(a)(2). Because this application was filed after June 30, 2003, copies of the U.S. Patents and U.S. patent publications listed on the enclosed Form 1449 are not provided.

No representation is made that a reference is "prior art" within the meaning of 35 U.S.C. §§ 102 and 103 and Applicants reserve the right, pursuant to 37 C.F.R. § 1.131 or otherwise, to establish that the reference(s) are not "prior art." Moreover, Applicants do not represent that a reference has been thoroughly reviewed or that any relevance of any portion of a reference is intended.

Consideration of the items listed is respectfully requested. Pursuant to the provisions of M.P.E.P. 609, it is requested that the Examiner return a copy of the attached Form 1449, marked as being considered and initialed by the Examiner, to the undersigned with the next official communication.

Please charge any additional fees or credit any overpayment to Deposit Account
No. 13-2725.

April 21, 2006

Date

P.O. Box 2903
Minneapolis, Minnesota 55402-0903
Telephone No. (202) 326-0300
Facsimile No. (202) 326-0778

23552

Patent & Trademark Office

Respectfully submitted,
MERCHANT & GOULD, P.C.



Steven B. Kelber
Registration No. 30,073

Christopher W. Raimund
Registration No. 47,258

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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U.S. PATENT DOCUMENTS							
EXAMINER INITIAL		DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	A	6,380,335	04/30/2002	Charmot et al.			
	B	2002/0051936	05/02/2002	Harada et al.			

FOREIGN PATENT DOCUMENTS								
		DOCUMENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							YES	NO
	C	05-188598	07/30/1993	Japan			AB	
	D	06-012452	01/21/1994	Japan			AB	
	E	2000-119307	04/25/2000	Japan			AB	
	F	2000-264914	09/26/2000	Japan			AB	
	G	2001-261733	09/26/2001	Japan			AB	
	H	2002-003533	01/09/2002	Japan			AB	
	I	2002-080523	03/19/2002	Japan			AB	
	J	2002-145955	05/22/2002	Japan			AB	
	K	2002-145972	05/22/2002	Japan			AB	
	L	2002-155118	05/28/2002	Japan			AB	
	M	2002-156750	05/31/2002	Japan			AB	
	N	2002-201232	07/19/2002	Japan			AB	
	O	2002-251009	09/06/2002	Japan			AB	
	P	2003-084436	03/19/2003	Japan			AB	
	Q	2003-238629	08/27/2003	Japan			AB	
	R	2003-322972	11/14/2003	Japan			AB	
	S	98/58974	12/30/1998	WIPO			AB	
	T	99/31144	06/24/1999	WIPO			AB	

EXAMINER	DATE CONSIDERED
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EXAMINER: Initial if the reference is considered, whether or not the citation is in conformance with MPEP 609. Draw a line through the citation if it is not in conformance and it is not considered. Include a copy of this form with the next communication to the Applicant.

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U.S. APPLICATION SERIAL NO.
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CONF. NO.
4015

INVENTOR(S)
Isao NISHIMURA et al.

EXAMINER (If known)
Unassigned

FILING DATE
June 28, 2005

ART UNIT (If known)
N/A

FOREIGN PATENT DOCUMENTS

U	99/35177	07/15/1999	WIPO			AB	
V	02/090397	11/14/2002	WIPO			AB	
W	98/01478	01/15/1998	WIPO			AB	

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

X	Bradford B. Wayland et al., "Living Radical Polymerization of Acrylates by Organocobalt Porphyrin Complexes," J. Am. Chem. Soc., 1994, 116, 7943-7944.
Y	Michael K. GEORGES et al., "Narrow Polydispersity Polystyrene by a Free-Radical Polymerization Process-Rate Enhancement," Macromolecules, 1994, 27, 7228-72296.
Z	Craig J. HAWKER et al., "Accurate Control of Chain Ends by a Novel "Living" Free-Radical Polymerization Process," Macromolecules, 1995, 28, 2993-2995.
AA	Chemical Handbook, Basic Chemistry, 4 th Ed (1993) by the Chemical Society of Japan.

EXAMINER

DATE CONSIDERED

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